Serial No. To be Assigned Filed: October 13, 2004

Amendments to the Specification:

On page 1, after the title "Nanoimprint resist", please insert the following:

This application is a United States National Stage Patent Application under 35 U.S.C. § 371 of International Patent Application No. PCT/EP03/03666, filed April 9, 2003, which claims priority to German Patent Application No. 102 17 151.3, filed April 17, 2002.